
Contents

Part I Tools for Nanoscience

1 Lithography and Etching Processes

<i>D. Mailly, C. Vieu</i>	3
1.1 Definitions and General Considerations	3
1.2 Photoresists	3
1.2.1 Example of Processing with a Polymer Resist	4
1.2.2 Sensitivity and Contrast	5
1.2.3 Example of a Positive Resist	7
1.2.4 Transfer Stage	8
1.3 Subtractive Pattern Transfer	9
1.3.1 Wet Etching	9
1.3.2 Dry Etching	11
1.3.3 Reactive Ion Etching	13
1.4 Additive Pattern Transfer	15
1.4.1 Lift-Off	15
1.4.2 Electrolytic Growth	16
1.5 Lithography	19
1.5.1 Overview of Lithographic Methods	19
1.5.2 Proximity and Contact Photolithography	20
1.5.3 Projection Photolithography	23
1.5.4 X-Ray Photolithography	26
1.5.5 Extreme UV Lithography	28
1.5.6 Electron Projection Lithography	28
1.5.7 Ion Projection Lithography	29
1.5.8 Electron Beam Lithography	30
1.5.9 Focussed Ion Beam (FIB) Lithography	35
1.5.10 Conclusion	39
References	40

2 Growth of Organised Nano-Objects on Prepatterned Surfaces

<i>M. Hanbücken, J. Eymery, S. Rousset</i>	41
2.1 Physical Phenomena in Substrate Pre patterning and Periodic Growth of Adsorbates	42
2.1.1 Surface Crystallography: Surface Energy and Surface Stress	42
2.1.2 Self-Organised Surfaces: Discontinuities in the Surface Stress	47
2.1.3 3D Growth: Energy Criterion and Competition Between Bulk Elastic Energy and Surface Energy.....	48
2.1.4 Role of the Chemical Potential as Driving Force Behind Adsorbate Growth. Curvature Effect and Elastic Stresses.....	52
2.2 Physical and Chemical Methods for Producing Nano-Objects	53
2.3 Growth of Nano-Objects on a Naturally Pre patterned Surface Using Its Intrinsic Properties	56
2.3.1 Growth of Self-Organised Surfaces	56
2.3.2 Uses for Growth on Vicinal Surfaces	57
2.4 Growth of Quantum Dots on a Pre patterned Surface by Imposing a Controlled Artificial Pattern	58
2.5 Growth of Nano-Objects on a Pre patterned Vicinal Surface by Combining Natural and Artificial Patterning.....	61
2.5.1 Pre patterning the Si(111) Vicinal Surface.....	61
2.5.2 Growth of Gold Nano-Objects on Pre patterned Si(111)....	63
2.6 Conclusion	64
References	65

3 Scanning Tunneling Microscopy

<i>D. Stiévenard</i>	69
3.1 Introduction.....	69
3.1.1 General Principles	69
3.1.2 General Setup	70
3.1.3 Tip Preparation	71
3.2 Tunnel Current	72
3.2.1 Tunnel Effect Between Tip and Sample	72
3.2.2 Tunnel Current: Tersoff–Hamann Theory	73
3.2.3 Extending the Tersoff–Hamann Theory	73
3.2.4 Resolution	74
3.2.5 Contrast	75
3.2.6 Measuring the Barrier Height	76
3.2.7 Examples	77
3.3 STM Spectroscopy	80
3.3.1 Elastic Current.....	80
3.3.2 Measuring the Band Gaps of III–V Semiconductors	82
3.3.3 Spectroscopy of Individual Quantum Dots	82
3.3.4 Inelastic Tunnel Current	84

3.4	Tip-Sample Interaction	85
3.4.1	Manipulation Modes	85
3.4.2	Local Chemistry	87
3.5	Conclusion	88
	References	89
4 Atomic Force Microscopy		
	<i>C. Frétiigny</i>	91
4.1	The Device	91
4.2	The Various Imaging Modes	92
4.3	Image Resolution	95
4.4	Contact Mode: Topography, Elasticity and Adhesion Imaging	98
4.4.1	Friction Mode	100
4.5	Resonant Modes	101
4.5.1	General Principles	101
4.5.2	Linear Resonant Mode	102
4.5.3	Nonlinear Resonant (Tapping) Mode	103
4.6	Force Measurements	107
4.6.1	Non-Contact Measurements	108
4.6.2	Elasticity and Adhesion Measurements on a Single Molecule	108
4.7	Magnetic and Electrical Measurements	109
4.7.1	Magnetic Measurements	109
4.7.2	Electrical Measurements	109
4.8	Measuring Mechanical Properties	112
4.8.1	Nanoindentation	112
4.8.2	Measuring Contact Stiffness	112
4.8.3	Contact Resonance Frequency	113
4.8.4	Friction Forces	114
4.9	Applications in Nanotechnology	115
4.10	Conclusion	118
	References	118
5 Near-Field Optics: From Experiment to Theory		
	<i>C. Boccara, R. Carminati</i>	121
5.1	Basic Ideas and the Nature of the Problem	121
5.1.1	Resolution, Near Field and Far Field	121
5.1.2	Brief History of Near-Field Methods	122
5.1.3	Near-Field Optical Microscopy: For What Purpose?	123
5.2	Photon Scanning Tunneling Microscope (PSTM)	123
5.2.1	Frustration of Evanescent Fields	124
5.2.2	PSTM Probe in an Evanescent Field: Scattering Model	124
5.2.3	Applications of PSTM	126
5.3	Apertureless Near-Field Microscope	126
5.3.1	Nano-Antenna Radiating to the Far Field	127
5.3.2	Source of Contrast: Scattering Sphere Model	127

5.3.3	Sharp-Point Effect. Tip Resolution and Efficiency	129
5.3.4	Field Enhancement Near a Metal Tip	129
5.3.5	Apertureless SNOM: Typical SNOM Setup	131
5.4	Aperture SNOM	133
5.4.1	Metal-Coated Fibre	133
5.4.2	Energy Transmission in a Tapered Metal-Coated Fibre	134
5.4.3	Applications of Aperture SNOM	136
5.5	Plane Wave Expansion. Diffraction Limit	137
5.5.1	Propagation of a Beam in Vacuum	138
5.5.2	Uncertainty Relations and Diffraction	140
5.5.3	Diffraction Limit	140
5.6	Beyond the Diffraction Limit:	
	Near Field and Evanescent Waves	142
5.6.1	Evanescent Waves. Length Scales	142
5.6.2	Uncertainty Relations Revisited	143
5.7	Electromagnetic Radiation. Near Field and Far Field	143
5.7.1	Radiation from an Elementary Source (Electric Dipole)	143
5.7.2	Far-Field Radiation. Diffraction Limit Revisited	144
5.7.3	Near-Field Radiation. Quasi-Static Limit	145
5.7.4	Towards a Model	146
5.8	Dipole Emission Near a Nanostructure	146
5.8.1	Radiative Damping of Dipole Emission	147
5.8.2	Free-Space Dipole Emission	148
5.8.3	Dipole Emission Near an Object	149
5.8.4	Link with the Quantum Approach	150
5.8.5	A Simple Example: Dipole Emission Near a Plane Mirror	151
5.8.6	Dipole Emission Near a Nanoparticle.	
	Radiative and Non-Radiative Coupling	152
	References	155
6 Emerging Nanolithographic Methods		
	<i>Y. Chen, A. Pépin</i>	157
6.1	Introduction	157
6.2	Nanoimprint Lithography	158
6.3	Applications of Nanoimprint Lithography	162
6.3.1	Microelectronics	162
6.3.2	Nanomagnetism	163
6.3.3	Nano-Optics	164
6.3.4	Chemistry and Biology	165
6.4	UV Nanoimprint Lithography (UV-NIL)	166
6.5	Nanoembossing	167
6.6	Soft Lithography	169
6.7	Near-Field Lithography	172
6.8	Conclusion	174
	References	174

Part II Nanoscale Objects

7 Clusters and Colloids

<i>A. Perez, P. Mélinon, J. Lermé, P.-F. Brevet</i>	179
7.1 Equilibrium Shape	180
7.1.1 Liquid-Drop Model	180
7.1.2 Wulff Polyhedron	182
7.1.3 Beyond the Wulff Polyhedron	183
7.1.4 Van der Waals Binding	189
7.1.5 Covalent Binding	190
7.1.6 Ionic Binding	192
7.2 Characteristic Quantity: Radius	193
7.2.1 Thermodynamic Quantities: Melting Temperature	193
7.2.2 Electronic Quantities	196
7.3 Characteristic Quantity: Fluctuations	200
7.3.1 Melting Temperature	200
7.3.2 Kubo Model	202
7.4 Specific Quantum Effects in Nanoscale Systems and Collective Excitations	206
7.4.1 Electronic Shell Structure	207
7.4.2 Electronic Supershells	217
7.4.3 Optical Properties. Collective Excitations	225
7.5 Preparation Methods	241
7.5.1 Gas Phase Physical Methods	241
7.5.2 Liquid Phase Chemical Methods	246
7.6 Cluster or Colloid Assemblies	252
7.6.1 Assemblies of Metallic Clusters	253
7.6.2 Deposition Techniques for Clusters and Colloids	254
7.6.3 Characteristic Mechanisms for the Formation of Nanostructures by Cluster Assembly ..	256
7.6.4 Examples of New Nanostructured Systems Prepared by Cluster Deposition	260
7.7 Conclusion and Prospects	266
References	277

8 Fullerenes and Carbon Nanotubes

<i>J.-P. Bourgoïn, A. Loiseau, J.-F. Nierengarten</i>	279
8.1 Introduction	279
8.2 Nanotubes and the Crystalline Forms of Carbon	280
8.2.1 Diamond and Graphite	280
8.2.2 Discovery of Fullerenes	281
8.2.3 Discovery of Carbon Nanotubes	281
8.3 Fullerenes	282
8.3.1 Structure of Fullerenes	282

8.3.2	Production of Fullerenes	284
8.3.3	Physicochemical Properties of Buckminsterfullerene	285
8.4	Carbon Nanotubes	289
8.4.1	Crystal Structure of Nanotubes	289
8.4.2	Electronic Structure of Carbon Nanotubes	292
8.4.3	Self-Organisation of Nanotubes	300
8.4.4	Chemical Varieties of Nanotubes	301
8.4.5	Synthesis of Nanotubes	302
8.4.6	Growth Mechanism for Carbon Nanotubes	305
8.4.7	Observation of Nanotubes	308
8.4.8	Properties of Nanotubes	311
8.4.9	From Science to Applications	313
8.5	Conclusion	318
	References	321

9 Nanowires

	<i>J.-C. Labrune, F. Palmino</i>	325
9.1	Fabrication of Nanowires	326
9.2	The Top-Down Approach	327
9.2.1	Soft Lithography	327
9.2.2	Near-Field Lithography	328
9.3	The Bottom-Up Approach	332
9.3.1	Self-Assembly on a Surface	332
9.3.2	VLS Synthesis	334
9.3.3	Use of Porous Matrices	335
9.4	Electrical Conduction in Nanowires	335
9.4.1	Electrical Contacts	336
9.4.2	Incoherent Transport	342
9.4.3	Atomic Chains and Molecules	342
9.5	Conclusion	344
	References	344

10 Nano-Objects

	<i>J.-F. Nierengarten, J.-L. Gallani, N. Solladié</i>	349
10.1	Dendrimers	349
10.1.1	Divergent Synthesis	350
10.1.2	Convergent Synthesis	352
10.2	Supramolecules	353
10.2.1	Self-Assembly by 3D Template Effect Induced by a Metal Cation	354
10.2.2	Self-Assembly by Hydrogen Bonding	359
10.2.3	Self-Assembly by Hydrophobic Interactions, π -Interactions and Charge Transfer Interactions	363
10.2.4	Molecular Machines	366

10.3 Polymolecular Assemblies 368
 10.3.1 Self-Assembly in the Bulk 369
 10.3.2 Self-Assembly on Surfaces 372
 References 378

Part III Properties and Applications

11 Ultimate Electronics

S. Galdin-Retailleau, A. Bournel, P. Dollfus 383
 11.1 CMOS Technology 386
 11.2 MOSFET Scaling 392
 11.2.1 Basic Principles 392
 11.2.2 Short Channel Effects 392
 11.2.3 Scaling Rules 393
 11.2.4 State of the Art: ITRS Roadmap 395
 11.2.5 Interconnects 398
 11.3 NanoMOS Devices 400
 11.3.1 Specific Problems 400
 11.3.2 Alternatives to Conventional MOSFET Devices 408
 11.4 Conclusion 412
 References 413

12 Alternative Electronics

J.-N. Patillon, D. Maily 417
 12.1 Characteristic Length Scales for Nanoscopic Components 418
 12.2 Single-Electron Devices (SED) 419
 12.2.1 Basic Ideas 419
 12.2.2 Transport by Coulomb Blockade 420
 12.2.3 Double Tunnel Junction 425
 12.2.4 Single-Electron Transistor 427
 12.3 Quantum Interference in Nanostructures 428
 12.3.1 Introduction 428
 12.3.2 Conductance and Transmission. The Landauer Formula ... 430
 12.3.3 Calculating the Correction 433
 12.3.4 Effect of Magnetic Fields 434
 12.3.5 Universal Conductance Fluctuations 435
 12.3.6 Cutoffs 437
 12.4 An Example of Interference: Aharonov–Bohm Effect 437
 12.5 Superconducting Nanoelectronics: RSFQ Logic 440
 12.5.1 Introduction 440
 12.5.2 Superconducting Logic Components 440
 12.5.3 Structure and Performance of RSFQ Components 442
 References 446

13 Molecular Electronics

<i>J.P. Bourgoin, D. Vuillaume, M. Goffman, A. Filoramo</i>	447
13.1 Basic Building Blocks: Choice, Wealth, Complexity	448
13.2 A Little History	449
13.3 Molecular Components	450
13.3.1 Electrodes and Contacts	450
13.3.2 Relationship Between Molecular Structure and Properties ..	456
13.3.3 Functions	469
13.4 Components Based on Nanotubes	479
13.4.1 Field-Effect Transistors	479
13.4.2 Single-Electron Transistors (SET)	486
13.5 From Components to Circuits	490
13.5.1 Fabrication Techniques	490
13.5.2 Circuit Architecture	497
13.6 Conclusion	498
References	499

14 Nanomagnetism and Spin Electronics

<i>C. Chappert, A. Barthélémy</i>	503
14.1 Nanomagnetism	504
14.1.1 Vacuum Magnetostatics	504
14.1.2 Magnetism in Matter: Fundamental Relations	505
14.1.3 Magnetism in Matter: Continuum Approximation	511
14.1.4 Novel Magnetic Effects on the Nanoscale	525
14.1.5 Magnetisation Dynamics in Magnetic Nanostructures	540
14.2 Spin Electronics	552
14.2.1 Description	552
14.2.2 Origins and Mechanisms of Spin Electronics	559
14.2.3 Magnetoresistance of Tunnel Junctions	568
References	578

15 Information Storage

<i>D. Fraboulet, Y. Samson</i>	583
15.1 Mass Memories	583
15.1.1 Mass Memories: The Hard Disk	585
15.1.2 Beyond the Hard Disk. Local Probe Techniques	593
15.2 Matrix Memories	595
15.2.1 General Principles of Matrix Storage	595
15.2.2 Difficulties in Reducing Memory Cells to Nanoscale Sizes ..	599
15.2.3 Matrix Memory Technology in Current Use	600
15.2.4 Memory Concepts Under Development	606
15.3 Conclusion	614
References	618

16 Optronics

<i>J.-L. Pautrat, J.-M. Gérard, É. Bustarret, D. Cassagne, E. Hadji, C. Seassal</i>	619
16.1 Surface Plasmons and Nanoscale Optics.....	619
16.1.1 Introduction.....	619
16.1.2 What Is a Plasmon?.....	620
16.1.3 Dispersion Relations, Coupling with Light, and Applications.....	622
16.1.4 Optical Transmission Through Subwavelength Apertures ..	627
16.1.5 Metal Nanoparticles.....	629
16.1.6 How Far Can Plasmons Take Us?.....	633
16.2 Semiconductor Quantum Dots.....	634
16.2.1 Semiconductor Lasers: From Quantum Wells to Quantum Dots.....	634
16.2.2 Single Quantum Dots.....	640
16.3 Photonic Crystals and Microcavities.....	646
16.3.1 Introduction.....	646
16.3.2 Periodic Structures.....	646
16.3.3 Structures Without Defects. Exploiting the Allowed Bands in Photonic Crystals.....	653
16.3.4 Structures with Defects.....	656
16.3.5 Conclusion and Prospects.....	661
References.....	662

17 Nanophotonics for Biology

<i>J. Zyss, S. Brasselet</i>	665
17.1 Emission and Absorption of Light by Molecular Systems.....	676
17.2 Molecules, Supramolecular Assemblies, and Nanoparticles.....	686
17.2.1 Coupling Between Nanoparticles and Biomolecules.....	686
17.2.2 Luminescent Nanostructures Based on Semiconductors and Metals.....	695
17.2.3 Molecular Engineering for Biophotonics.....	698
17.3 Nanophotonic Instrumentation for Biology.....	707
17.3.1 Optical Detection of Single Molecules by Fluorescence.....	707
17.3.2 Multiphoton and Nonlinear Microscopy.....	731
17.3.3 Mechanical Properties of Single Biomolecules.....	737
17.4 Conclusion.....	743
References.....	746

18 Numerical Simulation

<i>X. Blase, C. Delerue</i>	749
18.1 Structural Properties.....	750
18.1.1 Interatomic Potentials and Forces.....	750

18.1.2	Potential Energy Surface	752
18.1.3	Classical Molecular Dynamics	753
18.1.4	Monte Carlo Methods	755
18.2	Electron Properties	757
18.2.1	Basic Results from Quantum Mechanics	757
18.2.2	Semi-Empirical Approaches to Electron Structure	759
18.2.3	Ab Initio Methods	766
18.2.4	Ab Initio Calculation of Interatomic Forces	771
18.2.5	Using Electron Wave Functions and Eigenvalues	773
18.3	Conclusion	773
	References	774
19 Computer Architectures for Nanotechnology:		
Towards Nanocomputing		
	<i>C. Gamrat</i>	777
19.1	Introduction	777
19.2	Computer Architecture and Basic Functions	779
19.2.1	Typical Architecture of a Computer	779
19.2.2	Memory	780
19.2.3	Interconnects	782
19.2.4	Operators	782
19.2.5	Technological Considerations	783
19.2.6	Nanomemories, Nano-operators, Nanoconnections	785
19.3	Some Ideas for a New Architecture	786
19.3.1	Calculating with Memory Alone	786
19.3.2	Reconfigurable Computer Architectures	788
19.3.3	Cellular Automata	789
19.3.4	Neural Networks	791
19.4	Computer Environment	794
19.4.1	Information Coding	794
19.4.2	Defect Tolerance	794
19.5	Prospects	798
	References	799
	Index	801